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| APPLICATION NO.                   | FILING DATE | FIRST NAMED INVENTOR        | ATTORNEY DOCKET NO.  | CONFIRMATION NO. |
|-----------------------------------|-------------|-----------------------------|----------------------|------------------|
| 10/813,880                        | 03/30/2004  | April Dawn Hixson-Goldsmith | HSJ9-2003-0203US1    | 5758             |
| 32112                             | 7590        | 09/19/2006                  | EXAMINER             |                  |
| INTELLECTUAL PROPERTY LAW OFFICES |             |                             | MAGEE, CHRISTOPHER R |                  |
| 1901 S. BASCOM AVENUE, SUITE 660  |             |                             | ART UNIT             |                  |
| CAMPBELL, CA 95008                |             |                             | PAPER NUMBER         |                  |
|                                   |             |                             | 2627                 |                  |

DATE MAILED: 09/19/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

|                              |   |  |  |
|------------------------------|---|--|--|
| <b>Office Action Summary</b> | <b>Application No.</b><br>10/813,880    | <b>Applicant(s)</b><br>HIXSON-GOLDSMITH ET AL. |  |
|                              | <b>Examiner</b><br>Christopher R. Magee | <b>Art Unit</b><br>2627                        |  |

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

#### Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

#### Status

- 1) ☐ Responsive to communication(s) filed on \_\_\_\_.
- 2a) ☐ This action is **FINAL**.                      2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

#### Disposition of Claims

- 4) ☒ Claim(s) 1-30 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-30 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_ are subject to restriction and/or election requirement.

#### Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 01 July 2004 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

#### Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All    b) ☐ Some \* c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

#### Attachment(s)

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)  | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. ____. |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)   | 5) <input type="checkbox"/> Notice of Informal Patent Application                       |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)<br>Paper No(s)/Mail Date <u>3/30/04</u> . | 6) <input type="checkbox"/> Other: ____.  |

## DETAILED ACTION

### *Claim Rejections - 35 USC § 102*

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

- Claims 1-3, 6-9, 12, 13, 16, 17, 19, 21, 24, 26 and 27 are rejected under 35 U.S.C. 102(e)

as being anticipated by Chen et al. (hereinafter Chen) (US 6,724,569 B1).

- Regarding claims 1-3, 16 and 26, Chen discloses a hard disk drive comprising:

at least one hard disk 410 being adapted for rotary motion upon a disk drive;

at least one slider device 420 having a slider body portion being adapted to fly over said hard disk;

a magnetic head (100; part of merged head assembly 420) being formed on said slider body for writing data to said hard disk, said magnetic head [Figure 4] including:

a first magnetic pole 115;

a second magnetic pole 135;

a write gap layer 120 being disposed between said first and second magnetic poles, where said write gap layer includes at least two sublayers 120a, 120c, including an adhesion sublayer and an electrically conductive, non-magnetic sublayer [i.e., layers may be formed of the same, or of different materials; col. 6, lines 6-10].

As the claims are directed to a magnetic head, per se, the method limitation(s) appearing in claim 2, claim 3, claim 17 and lines 2 to 8 of claim 26, can only be accorded weight to the extent that it/they affect the structure of the completed magnetic head. Note that “[d]etermination of patentability in ‘product-by-process’ claims is based on product itself, even though such claims are limited and defined by process [i.e., “*electroplating*”; “*electroplating a second magnetic pole upon said electrically conductive, non-magnetic sublayer*”, for instance], and thus product in such claim is unpatentable if it is the same as, or obvious form, product of prior art, even if prior product was made by a different process”, *In re Thorpe, et al.*, 227 USPQ 964 (CAFC 1985). Furthermore, note that a “[p]roduct-by-process claim, although reciting subject matter of claim in terms of how it is made [i.e., “*electroplating*”; “*electroplating a second magnetic pole upon said electrically conductive, non-magnetic sublayer*”, for instance], is still product claim; it is patentability of product claimed and not recited process steps that must be established, in spite of fact that claim may recite only process limitations”, *In re Hirao and Sato*, 190 USPQ 685 (CCPA 1976).

- Regarding claims 6-9, 12, 13, 19, 21, 24 and 27, Chen discloses the gap sublayers are about 200 Angstroms [col. 5, lines 60-64]. Where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation and optimization in the absence of criticality. *In re Swain et al.*, 33 CCPA (Patents) 1250, 156 F2d 239, 70 USPQ 412; *Minnesota Mining and Mfg. Co. v. Coe*, 69 App. D.C. 217, 99 F2d 986, 38 USPQ 213; *Allen et al. v. Coe*, 77 App. D.C. 324, 135 F2d 11, 57 USPQ 136.

***Claim Rejections - 35 USC § 103***

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

- Claims 4, 5, 10, 11, 14, 15, 17, 20, 22, 23, 25 and 28-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen et al. (hereinafter Chen) (US 6,724,569 B1) as applied to claims 1 and 16 above, and further in view of Han et al. (hereinafter Han) (US 6,960,281 B1).

- Regarding claims 4 and 17, Chen discloses all the features, *supra*, except said adhesion layer is comprised of a material selected from the group consisting of Ta, Ti, Cr or NiCr.

Regarding claims 5, 20 and 28, Chen discloses all the features, *supra*, except said electrically conductive, non-magnetic sublayer is comprised of a material selected from the group consisting of Rh, Ru, Ir, Mo, W, Au, Be, Pd, Pt, Cu, PtMn and Ta.

Regarding claims 10 and 22, Chen discloses all the features, *supra*, except the second magnetic pole is comprised of a CoFe alloy.

Han teaches the use of gap-filling materials NiCr, Cr, NiFeCr, Rh and Ru, that satisfy the equal etch rate criterion of both the shield layer material, the seed layer materials and plated pole portion [col. 3, lines 10-25]. Also, Han teaches a pole piece comprised of a CoFe alloy (i.e., CoNiFe) [col. 3, lines 38-41].

It would have been obvious to one of ordinary skill in the art at the time the invention was made to provide the gap sublayers and the second magnetic pole of Chen with the materials as taught by Han.

The rationale is as follows: One of ordinary skill in the art at the time of the invention would have been motivated to provide the gap sublayers and the second magnetic pole of Chen with the materials as taught by Han because they are known gap layer materials that are used in magnetic heads and using them is merely a substitution of art recognized equivalents.

- Regarding claims 11, 14, 15, 23, 25, 29 and 30, Chen discloses said write gap layer 120 also includes a third sublayer 120b that is disposed between said adhesion layer and said electrically conductive, non-magnetic sublayer. Chen does teach the third sublayer is comprised of a material that is etchable in reactive ion etch process.

Han teaches the use of gap-filling materials NiCr, Cr, NiFeCr, Rh and Ru, that satisfy the equal etch rate criterion of both the shield layer material, the seed layer materials and plated pole portion [col. 3, lines 10-25].

It would have been obvious to one of ordinary skill in the art at the time the invention was made to provide the gap sublayers of Chen with a third sublayer material as taught by Han.

The rationale is as follows: One of ordinary skill in the art at the time of the invention would have been motivated to provide the gap sublayers of Chen with the a third sublayer material as taught by Han because they are known gap layer materials that are used in magnetic heads and using them is merely a substitution of art recognized equivalents. Plus, the IBE rate is substantially the same as the IBE rate of both the shield layer and the materials of the seed layer and plated pole portion [Han; col. 3, lines 17-20].

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***Conclusion***

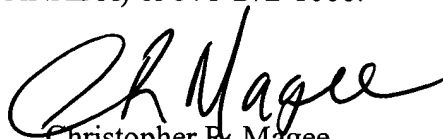
3. The prior art made of record and not relied upon that is considered pertinent to applicant's disclosure has been annotated on PTO-492.

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Christopher R. Magee whose telephone number is (571) 272-7592. The examiner can normally be reached on M-F, 8: 00 am-4: 30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William Korzuch can be reached on (571) 272-7589. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

  
**ANGEL CASTRO**  
**PRIMARY EXAMINER**

  
Christopher R. Magee  
Patent Examiner  
Art Unit 2627

September 15, 2006  
crm